

Attorney's Docket No.: 042390.P3955D

Patent

El.  
H609  
13J

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of: )  
Andideh, E. et al. )  
U.S. Serial No: 09/436,092 )  
Filed: November 8, 1999 )  
For: POLISH PAD WITH )  
NON-UNIFORM GROOVE DEPTH )  
TO IMPROVE WAFER POLISH RATE )  
UNIFORMITY )

Examiner: McDonald, Shantese

Art Unit: 3723

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GROUP 3700

Assistant Commissioner for Patents  
Washington, D.C. 20231

AMENDMENT AND RESPONSE

Dear Sir:

This is in response to the Office Action mailed August 28, 2001. Applicant respectfully requests the Examiner to enter the following amendments and consider the following remarks.

FIRST CLASS CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail with sufficient postage in an envelope addressed to the Assistant Commissioner of Patents, Washington, D.C. 20231

on January 28, 2002 Date of Deposit

Teresa Edwards

Name of Person Mailing Correspondence

Teresa Edwards  
Signature

January 28, 2002  
Date

1

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